

# 18.69% PCE from organic solar cells

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## SUPPORTING INFORMATION

### 1. Device fabrication and measurements

#### Conventional solar cells

A 30 nm thick PEDOT:PSS layer was made by spin-coating an aqueous dispersion onto ITO glass (4000 rpm for 30 s). PEDOT:PSS substrates were dried at 150 °C for 10 min. A blend solution of D18-Cl ( $M_n$ : 70.5 kDa, PDI: 2.27), N3 and PC<sub>61</sub>BM in chloroform (13 mg/mL) with 0.3 vol% DPE additive was spin-coated onto PEDOT:PSS layer. PDIN (2 mg/mL) in MeOH:AcOH (1000 : 3) was spin-coated onto active layer (5000 rpm for 30 s). Ag (~80 nm) was evaporated onto PDIN through a shadow mask (pressure ca. 10<sup>-4</sup> Pa). The device area is 4 mm<sup>2</sup>. The thicknesses of the active layers were measured by using a KLA Tencor D-120 profilometer. The illumination intensity of solar simulator was determined by using a monocrystalline silicon solar cell (Enli SRC2020, 2 × 2 cm<sup>2</sup>) calibrated by the National Institute of Metrology (NIM). *J-V* curves were measured by using a computerized Keithley 2400 SourceMeter and a Xenon-lamp-based solar simulator (Enli Tech, AM 1.5G, 100 mW/cm<sup>2</sup>). When doing *J-V* measurements, a metal mask with an aperture (2.56 mm<sup>2</sup>) was used to define the effective area. The external quantum efficiency (EQE) spectra were measured by using a QE-R3011 measurement system (Enli Tech). The best cells were further test-

ed at NIM for certification. A metal mask with an aperture (2.580 mm<sup>2</sup>) was used to define the effective area.

#### Hole-only devices

The structure for hole-only devices is ITO/PEDOT:PSS/active layer/MoO<sub>3</sub>/Al. A 30 nm thick PEDOT:PSS layer was made by spin-coating an aqueous dispersion onto ITO glass (4000 rpm for 30 s). PEDOT:PSS substrates were dried at 150 °C for 10 min. A D18-Cl:N3:PC<sub>61</sub>BM (or D18-Cl:N3) blend in CF was spin-coated onto PEDOT:PSS. Finally, MoO<sub>3</sub> (~6 nm) and Al (~100 nm) were successively evaporated onto the active layer through a shadow mask (pressure ca. 10<sup>-4</sup> Pa). *J-V* curves were measured by using a computerized Keithley 2400 SourceMeter in the dark.

#### Electron-only devices

The structure for electron-only devices is ITO/ZnO/active layer/PDIN/Al. The ZnO precursor solution was spin-coated onto ITO glass (4000 rpm for 30 s). The films were annealed at 200 °C in air for 20 min. ZnO film thickness is ~30 nm. A D18-Cl:N3:PC<sub>61</sub>BM (or D18-Cl:N3) blend in CF was spin-coated onto ZnO. PDIN (2 mg/mL) in MeOH:AcOH (1000 : 3) was spin-coated onto active layer (5000 rpm for 30 s). Al (~100 nm) was evaporated onto the active layer through a shadow mask (pressure ca. 10<sup>-4</sup> Pa). *J-V* curves were measured by using a computerized Keithley 2400 SourceMeter in the dark.

### 2. Optimization of device performance

Table S1. Optimization of D : A<sub>1</sub> : A<sub>2</sub> ratio for D18-Cl:N3:PC<sub>61</sub>BM solar cells<sup>a</sup>.

D : A <sub>1</sub> : A <sub>2</sub> (w/w/w)	V <sub>oc</sub> (V)	J <sub>sc</sub> (mA/cm <sup>2</sup> )	FF (%)	PCE (%)
1 : 1.4 : 0	0.847	27.56	76.5	17.85 (17.82) <sup>b</sup>
1 : 1.4 : 0.1	0.846	27.86	77.2	18.19 (18.14)
1 : 1.4 : 0.2	0.843	27.72	77.3	18.05 (17.90)
1 : 1.4 : 0.3	0.841	27.59	76.8	17.82 (17.71)

<sup>a</sup>Blend solution: 13 mg/mL in CF with 0.3 vol% DPE; spin-coating: 4000 rpm for 30 s.

<sup>b</sup>Data in parentheses stand for the average PCEs for 10 cells.

Table S2. Optimization of DPE content for D18-Cl:N3:PC<sub>61</sub>BM (1 : 1.4 : 0.1) solar cells<sup>a</sup>.

DPE (vol%)	V <sub>oc</sub> (V)	J <sub>sc</sub> (mA/cm <sup>2</sup> )	FF (%)	PCE (%)
0	0.853	26.83	77.6	17.75 (17.69) <sup>b</sup>
0.3	0.846	27.86	77.2	18.19 (18.14)
0.6	0.842	27.77	77.0	18.00 (17.84)
0.9	0.841	27.70	76.2	17.75 (17.70)

<sup>a</sup>Blend solution: 13 mg/mL in CF; spin-coating: 4000 rpm for 30 s.

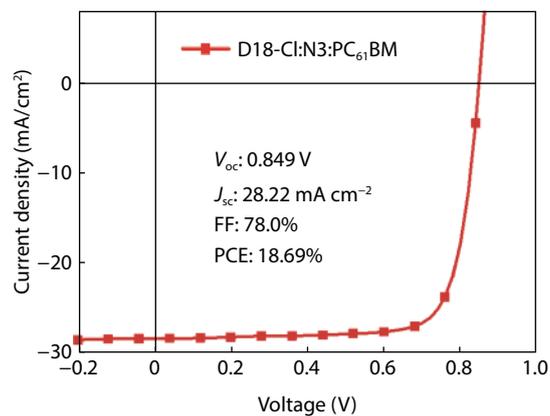
<sup>b</sup>Data in parentheses stand for the average PCEs for 10 cells.

Table S3. Optimization of the active layer thickness for D18-Cl:N3:PC<sub>61</sub>BM (1 : 1.4 : 0.1) solar cells<sup>a</sup>.

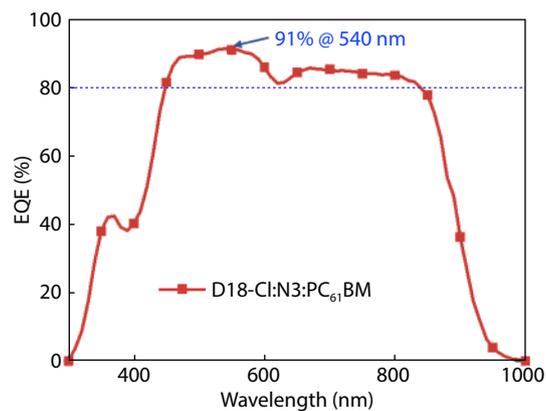
Thickness (nm)	$V_{oc}$ (V)	$J_{sc}$ (mA/cm <sup>2</sup> )	FF (%)	PCE (%)
158	0.837	27.61	76.7	17.73 (17.51) <sup>b</sup>
130	0.846	27.86	77.2	18.19 (18.14)
114	0.849	28.22	78.0	18.69 (18.47)
103	0.847	27.45	78.3	18.21 (18.17)

<sup>a</sup>Blend solution: 13 mg/mL in CF with 0.3 vol% DPE.<sup>b</sup>Data in parentheses stand for the average PCEs for 10 cells.

### 3. $J-V$

Fig. S1. The  $J-V$  curve for the best D18-Cl:N3:PC<sub>61</sub>BM cell.

### 4. EQE

Fig. S2. The EQE spectrum for the best D18-Cl:N3:PC<sub>61</sub>BM cell.

## 5. NIM certification

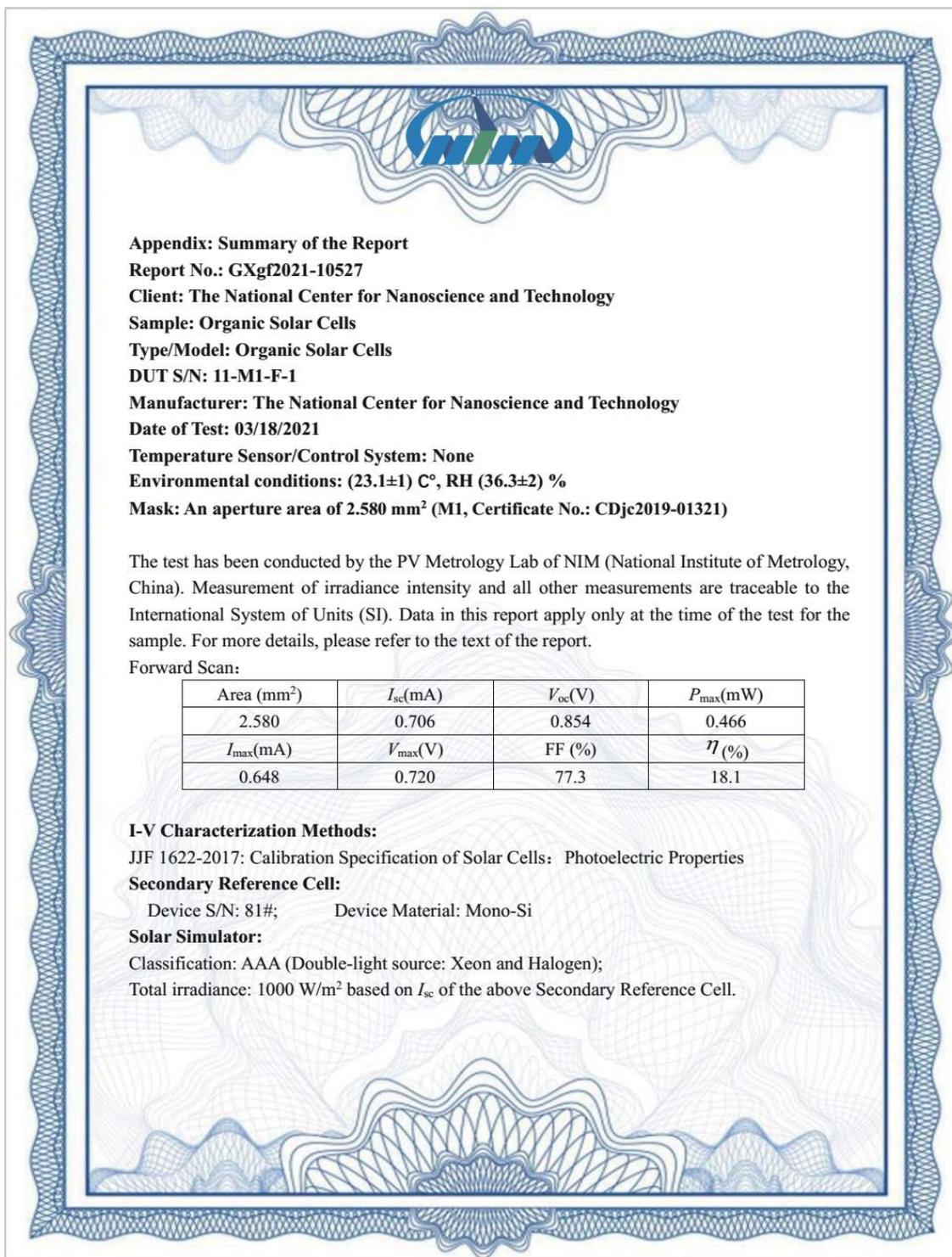


Fig. S3. NIM (Beijing) report for D18-Cl:N3:PC<sub>61</sub>BM solar cells.

## 6. SCLC

Charge carrier mobility was measured by SCLC method. The mobility was determined by fitting the dark current to the model of a single carrier SCLC, which is described by:

$$J = \frac{9}{8} \varepsilon_0 \varepsilon_r \mu \frac{V^2}{d^3},$$

where  $J$  is the current density,  $\mu$  is the zero-field mobility of holes ( $\mu_h$ ) or electrons ( $\mu_e$ ),  $\varepsilon_0$  is the permittivity of the vacuum,  $\varepsilon_r$  is the relative permittivity of the material,  $d$  is the thickness of the blend film, and  $V$  is the effective voltage ( $V = V_{appl} - V_{bi}$ , where  $V_{appl}$  is the applied voltage, and  $V_{bi}$  is the built-in potential determined by electrode work function difference). Here,  $V_{bi} = 0.1$  V for hole-only devices,  $V_{bi} = 0$  V for electron-only devices<sup>[1]</sup>. The mobility was calculated from the slope of  $J^{1/2}$ - $V$  plot.

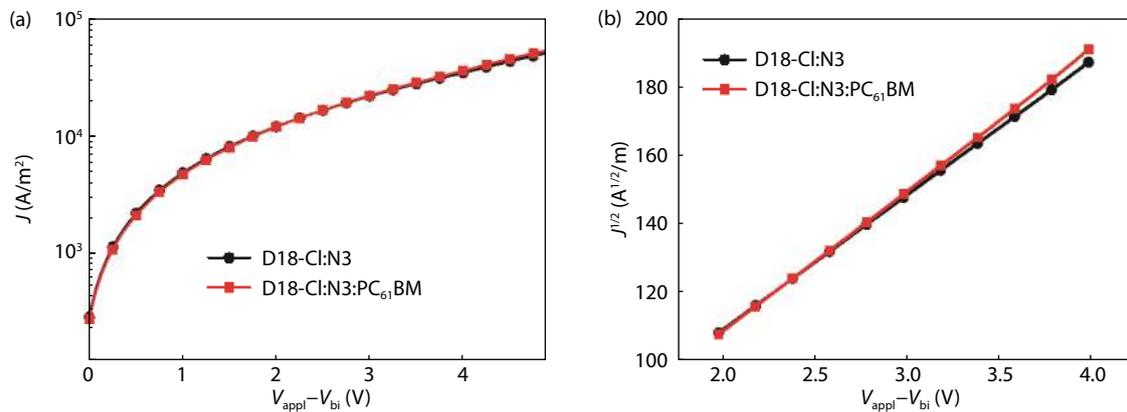


Fig. S4. (a)  $J$ - $V$  curves and (b) corresponding  $J^{1/2}$ - $V$  plots for the hole-only devices (in dark). The thicknesses for D18-Cl:N3 (1 : 1.4) and D18-Cl:N3:PC<sub>61</sub>BM (1 : 1.4 : 0.1) films are 118 and 115 nm, respectively.

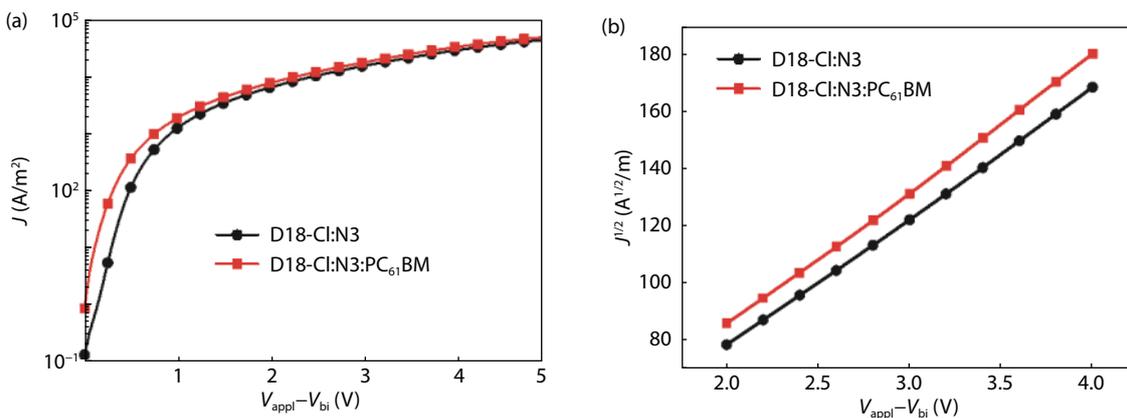


Fig. S5. (a)  $J$ - $V$  curves and (b) corresponding  $J^{1/2}$ - $V$  plots for the electron-only devices (in dark). The thicknesses for D18-Cl:N3 (1 : 1.4) and D18-Cl:N3:PC<sub>61</sub>BM (1 : 1.4 : 0.1) films are 98 and 100 nm, respectively.

Table S4. Hole and electron mobilities.

Film	$\mu_h$ (cm <sup>2</sup> /(V·s))	$\mu_e$ (cm <sup>2</sup> /(V·s))	$\mu_h/\mu_e$
D18-Cl:N3 (1 : 1.4)	$8.18 \times 10^{-4}$	$6.32 \times 10^{-4}$	1.29
D18-Cl:N3:PC <sub>61</sub> BM (1 : 1.4 : 0.1)	$8.34 \times 10^{-4}$	$7.42 \times 10^{-4}$	1.12

## References

[1] Duan C, Cai W, Hsu B, et al. Toward green solvent processable

photovoltaic materials for polymer solar cells: the role of highly polar pendant groups in charge carrier transport and photovoltaic behavior. *Energy Environ Sci*, 2013, 6, 3022